



IPW

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Attorney Docket No: 40296-0039

In re patent application of:
Chang Rock Song et al.

Confirmation No.: 6185

Serial No.: 10/721,092

Art Unit: 2812

Filed: November 26, 2003

Examiner: Jennifer M. Kennedy

For: METHOD FOR MANUFACTURING A CAPACITOR OF A SEMICONDUCTOR
DEVICE

RESPONSE TO RESTRICTION REQUIREMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In response to the Office Action mailed April 5, 2005, applicants hereby elect without traverse Group I, Claims 1-11 drawn to method for manufacturing a capacitor of a semiconductor device having a dielectric of an ONO structure, for prosecution in the subject application. Applicants, of course, reserve the right to file one or more divisional applications covering the subject matter of the non-elected claims.

It is respectfully submitted that the application is in condition for examination, and an early action on the merits is courteously requested.

Date: 5/4/05

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Respectfully submitted,

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